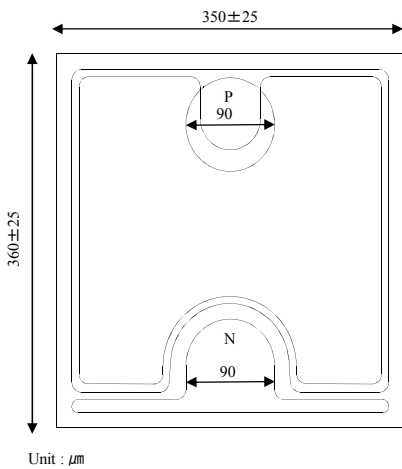


(1) Chip Description

● Mechanical Specification

Description	Dimension
Bottom Area	350 μ m x 360 μ m \pm 25 μ m
Chip Thickness	120 μ m \pm 10 μ m
N Bonding Pad Electrode	90 μ m \pm 5 μ m
P Bonding Pad Electrode	90 μ m \pm 5 μ m



● Material

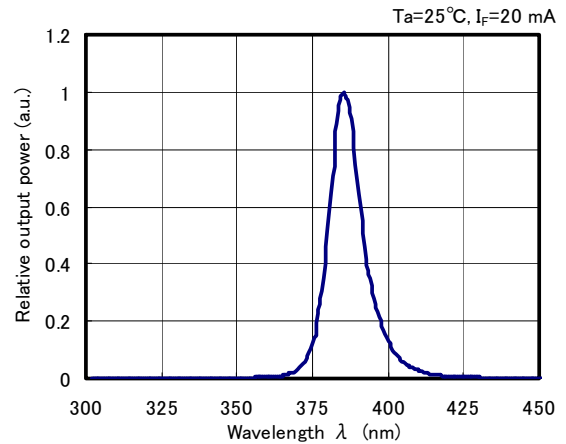
Substrate : Sapphire

Epitaxial Layer : GaN Based Material

N Bonding Pad Electrode : Au alloy

P Bonding Pad Electrode : Au alloy

(2) Spectrum



(3) Optical and Electrical Characteristics (Ta=25°C)

Item	Symbol	Condition	Min.	Typ.	Max.	Unit
Forward Voltage	V_F	$I_F=20\text{mA}$	3.2	3.5	4.2	V
Reverse Current	I_R	$V_R=5\text{V}$	-	-	10	μ A
Peak Wavelength*1	λ_p	$I_F=20\text{mA}$	380	-	390	nm
Full Width at Half Maximum	$\Delta\lambda$	$I_F=20\text{mA}$	10	-	20	nm
Optical Output Power *2	P_o	$I_F=20\text{mA}$	7.0	-	8.0	mW

*1 Measurement error is $\pm 2\text{nm}$

*2 Measurement error is $\pm 10\%$



CAUTION

- LEDs emit very strong UV radiation.
- Don't look directly into the LED light. UV radiation can harm your eyes.
- To prevent even inadequate exposure, wear protective eyewear.
- If LEDs are embedded in devices, please indicate warning labels against the UV light LED used.
- Keep out of reach of children.
- UV LED chips are very sensitive to static and surge. Take a full protection from static.

Specification and dimension are subject to change for improvement without notice.